

L Number	Hits	Search Text	DB	Time stamp
1	42682	polysilicon	USPAT	2003/06/24 08:30
2	7720	stringer	USPAT	2003/06/24 08:30
3	258	polysilicon with stringer	USPAT	2003/06/24 07:40
4	749157	convert\$3	USPAT	2003/06/24 06:57
5	0	(polysilicon with stringer) with convert\$3	USPAT	2003/06/24 06:58
6	488384	insulat\$3 dielectric	USPAT	2003/06/24 06:59
7	26	(polysilicon with stringer) with (insulat\$3 dielectric)	USPAT	2003/06/24 07:11
8	265941	residue residues	USPAT	2003/06/24 08:05
9	387	polysilicon with (residue residues)	USPAT	2003/06/24 07:12
10	269044	oxidized oxidizing oxidation	USPAT	2003/06/24 08:05
11	21	(polysilicon with (residue residues)) with (oxidized oxidizing oxidation)	USPAT	2003/06/24 07:29
12	59	(polysilicon with (residue residues)) same (oxidized oxidizing oxidation)	USPAT	2003/06/24 07:29
13	38	((polysilicon with (residue residues)) same (oxidized oxidizing oxidation)) not ((polysilicon with (residue residues)) with (oxidized oxidizing oxidation))	USPAT	2003/06/24 07:29
14	18	(((polysilicon with (residue residues)) same (oxidized oxidizing oxidation)) not ((polysilicon with (residue residues)) with (oxidized oxidizing oxidation)))) and @ad<19960212	USPAT	2003/06/24 07:30
15	324	polysilicon same stringer	USPAT	2003/06/24 07:40
16	27	(oxidized oxidizing oxidation) same (polysilicon same stringer)	USPAT	2003/06/24 07:40
17	11431	polysilicon	JPO	2003/06/24 08:22
18	34054	residue residues	JPO	2003/06/24 08:22
19	94568	oxidized oxidizing oxidation	JPO	2003/06/24 08:22
20	21	polysilicon and (residue residues) and (oxidized oxidizing oxidation)	JPO	2003/06/24 08:23
21	12502	residue residues	EPO	2003/06/24 08:27
22	1311	polysilicon	EPO	2003/06/24 08:22
23	12987	oxidized oxidizing oxidation	EPO	2003/06/24 08:31
24	306	stringer	JPO	2003/06/24 08:26
25	4	polysilicon and stringer and (oxidized oxidizing oxidation)	JPO	2003/06/24 08:23
26	553	stringer	EPO	2003/06/24 08:26
27	0	(residue residues) same (oxidized oxidizing oxidation) same stringer	EPO	2003/06/24 08:27
28	0	polysilicon same (oxidized oxidizing oxidation) same stringer	EPO	2003/06/24 08:29
29	0	polysilicon and (oxidized oxidizing oxidation) and stringer	EPO	2003/06/24 08:29
30	0	polysilicon same (oxidized oxidizing oxidation) same (residue residues)	EPO	2003/06/24 08:29
31	0	polysilicon and (oxidized oxidizing oxidation) and (residue residues)	EPO	2003/06/24 08:29
32	10	stringer	IBM_TDB	2003/06/24 08:30
33	1308	polysilicon	IBM_TDB	2003/06/24 08:30
34	1844	oxidized oxidizing oxidation	IBM_TDB	2003/06/24 08:31
35	0	stringer and polysilicon and (oxidized oxidizing oxidation)	IBM_TDB	2003/06/24 08:31